10542040 - GAU: 1795

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INFORMATION DIGGLOGUES	Filing Date	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	First Named Inventor	John
(Not for submission under 37 CFR 1.99)	Art Unit	

Application Number	10542040
Filing Date	2006-02-06
First Named Inventor	John Mize
Art Unit	1795
Examiner Name	Jason Berman
Attomey Docket Numi	er H0004870.70759 US -4015

			,	U.S	S.PATENTS	~~~
Examiner Initial*	Cite No	Patent Number	Kind Code <sup>1</sup>	Issue Date	Name of Patentee or Applicant of cited Document	Pages, Columns, Lines where Relevant Passages or Relevan Figures Appear
	1			Marie 111 Malabababara		
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			U.S.P	ATENT APPL	ICATION PUBLICATIONS	
Examiner Initial*	Cite No	Publication Number	Kind Code <sup>1</sup>	Publication Date	Name of Patentee or Applicant of cited Document	Pages,Columns,Lines where Relevant Passages or Relevant Figures Appear
	1	20040256217	A1	2004-12-23	Applied Materials, Inc.	
	2	20060070875	A1	2006-04-06	Applied Materials, Inc.	
	3	20010007302	A1	2001-07-12	Liubo Hong	
	4	20080318433	A1	2008-12-25	Lam Research Corporation	
	5	20080038481	A1	2008-02-14	Applied Materials, Inc.	

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## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

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Examiner Name Jason		n Berman				
Attorney Docket Number		H0004870.70759 US -4015				

	6	20050048876	A1	2005-03-03	Applied Materials, Inc.
7.	7	20070059460	A1	2007-03-15	Applied Materials, Inc.
	8	20070283884	A1	2007-12-13	Applied Materials, Inc.
	9	20070173059	A1	2007-07-26	Applied Materials, Inc.
	10	20070170052	A1	2007-07-26	Applied Materials, Inc.
	11	20070125646	A1	2007-06-07	Applied Materials, Inc.
	12	20080196661	A1	2008-08-21	Brian West
	13	20080156264	A1	2008-07-03	Novellus Systems, Inc.
	14	20080164146	A1	2008-07-10	Tosoh SMD, Inc.
	15	20060278341	A1	2006-12-14	Samsung Electronics Co., Ltd.
	16	20030000648	A1	2003-01-02	Samsung Electronics Co., Ltd.
				A	.i

INFORMATION DISCLOSURE	Application Number		10542040	10542040 - GAU: 179	
	Filing Date	-	2006-02-06		
·	First Named Inventor	John	Mize		
	Art Unit	*******	1795		
(Not for submission under 57 of K 1.55)	Examiner Name	Jasor	Berman		

H0004870.70759 US -4015

Attorney Docket Number

	17	20070051472	A1	2007-03-08	Tokyo Electron Limited
	18	20070215279	A1	2007-09-20	Tokyo Electron Limited
	19	20070169891	A1	2007-07-26	Tokyo Electron Limited
	20	20080000876	A1	2008-01-03	Hynix Semiconductor Inc.
-	21	20080066868	A1	2008-03-20	Tokyo Electron Limited
	22	20080087382	A1	2008-04-17	Tokyo Electron Limited
	23	20080149595	A1	2008-06-26	Peter Cirigliano
The state of the s	24	20060172542	A1	2006-08-03	Applied Materials, Inc.
Maria Maria	25	20060193102	A1	2006-08-31	Kallol Bera, et al.
	26	20070023145	A1	2007-02-01	Kallol Bera, et al.
	27	20080110760	A1	2008-05-15	Applied Materiais, Inc.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /J.B./

Receipt date: 04/21/2009

## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

( Not for submission under 37 CFR 1.99)

			10542040 - GAU: 1795		
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Examiner Name Jason		Berman			
Attorney Docket Number		H0004970 7075	0 UC 4045		

		T			
	28	20080223725	A1	2008-09-18	Applied Materials. Inc.
7.7.200	29	20080017516	A1	2008-01-24	Applied Materials, Inc.
	30	20090041951	A1	2009-02-12	Lam Research Corporation
	31	20080041820	A1	2008-02-21	Lam Research Corporation
	32	20080156264	A1	2008-07-03	Novellus Systems, Inc.
	33	20070062452	A1	2007-03-22	Applied Materials, Inc.
	34	20040118521	A1	2004-06-24	Applied Materials, Inc.
	35	20070102286	A1	2007-05-10	Applied Materials, Inc.
	36	20070051472	A1	2007-03-08	Tokyo Electron Limited
	37	20080066868	A1	2008-03-20	Tokyo Electron Limited
	38	20070215279	A1	2007-09-20	Tokyo Electron Limited

STATEMENT BY APPLICANT
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Examiner Name	Jason Berman

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	40	20080178801	A1	2008-07-31	Applied Materials, Inc.
TOTAL TANAMAN TO A TOTAL TO A TOT	41	20060254717	A1	2006-11-16	Hiroyuki Kobayashi, et al.
	42	20070151947	A1	2007-07-05	Teong Su Song, et al.
	43	20080280066	A1	2008-11-13	Corus Technology BV
	44	20070034154	A1	2007-02-15	Tokyo Electron Limited
	45	20070181064	A1	2007-08-09	Tokyo Electron Limited
V III V	46	20080110747	A1	2008-05-15	Applied Materials, Inc.
	47	20050006222	Á1	2005-01-13	Peijun Ding, et al.
	48	20050255691	A1	2005-11-17	Applied Materials, Inc.
	49	20050199491	A1	2005-09-15	Applied Materials, Inc.
		1		1	

INFORMATION DIGGLOCULE		Filing Date				2006-02-06					
		TION DISCLOS		First N	Named I	nventor	John	Mize	Mize		
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	50	20070134907	A1	2007-06	5-14	Tokyo Ele	ctron L	imited			
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		itial if reference consid	dered, wh					mance with MPEP 609 th next communication	Draw line through a		
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